

“Progress and prospects in nanoscale dry processes: How can we control atomic layer reactions?”. Ishikawa K, Karahashi K, Ichiki T, Chang JP, George SM, Kessels WMM, Lee HJ, Tinck S, Um JH, Kinoshita K, Japanese journal of applied physics **56**, 06HA02 (2017). <http://doi.org/10.7567/JJAP.56.06HA02>